

# Controlling Third-Order Nonlinearities by Ion-Implantation Quantum-Well Intermixing

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**Abstract**—The optical Kerr effect was measured by observing self-phase modulation in GaAs–AlGaAs superlattice-core waveguides modified by ion-implantation quantum-well intermixing. The band-gap energy was shifted by 68 nm for an implantation dose of  $0.5 \times 10^{13} \text{ cm}^{-2}$  and annealing temperature of 775 °C. The Kerr effect was suppressed by up to 71% in the transverse-electric polarization after intermixing. A reduced polarization dependence of the self-phase modulation was observed after intermixing.

**Index Terms**—Nonlinear optics, optical Kerr effect, quantum-well intermixing (QWI), semiconductor superlattice.

COMPOUND semiconductors have led the way towards monolithically integrated all-optical signal processing devices. Mature fabrication technologies have allowed the development of low-loss waveguides and advanced structures such as Bragg reflection waveguides [1], passive mode converters [2], and cascaded microring resonators [3]. AlGaAs is of particular interest since the optical Kerr effect, a third-order nonlinearity, has been shown to be 500 times stronger than in silica [4]. These nonlinearities are nonresonant and do not rely on free-carrier plasma dispersion effects since the operating wavelengths are typically below the half-band-gap energy. This has opened the possibility of all-optical switching devices such as nonlinear directional couplers (NLDCs) [5] and nonlinear Mach–Zehnder interferometers (NLMZIs) [6] with ultrafast response times necessary for ultrahigh-speed communications systems and signal processing. Multiple quantum-well (MQW) structures based on AlGaAs permit greater flexibility to tailor the band-gap energy to suit the optical properties required for particular applications. Furthermore, the band-gap energy of MQWs can be modified after wafer growth by quantum-well intermixing (QWI) techniques [7]. This cost-effective approach allows selective control

of the electronic and optical properties of the material in specific regions defined using standard lithographic techniques. Already, QWI has been utilized to fabricate NLMZIs [8], asymmetric nonlinear waveguides for soliton emission [9], and quasi-phase-matching (QPM) gratings [10]. While several QWI methods are available, ion-implantation-induced QWI has been shown to produce superior resolution [11], which is a requirement for devices such as QPM gratings. Deep-well semiconductor superlattices have attracted attention as the greater fill-factor and large band discontinuity in comparison to conventional quantum-well structures potentially provides a larger modification to nonresonant optical properties such as the refractive index and nonlinear optical susceptibilities in the transparency window for the complete structure. Thus, shorter and more efficient devices that require less power to operate are possible. In this letter, we demonstrate large modifications of the optical Kerr effect in GaAs–AlGaAs superlattice-core waveguides induced by ion-implantation QWI at wavelengths near the half-band-gap.

We have previously reported on the large polarization dependence of the Kerr coefficient in GaAs–AlAs superlattice waveguides [12]. However, measurements indicated the presence of parasitic two-photon absorption (TPA) resonances due to the reduced barrier resulting in asymmetric quantum wells (ASQW) found on either side of the superlattice waveguide core. In the present study, we modified the waveguide structure with several improvements. The new core layer was a 600-nm-thick superlattice of 75 periods each with 14:14 monolayers of GaAs:Al<sub>0.85</sub>Ga<sub>0.15</sub>As. The Al<sub>0.85</sub>Ga<sub>0.15</sub>As layers were substituted for the AlAs layers in the original superlattice to avoid the detrimental effects of oxidation. However, this change reduced the maximum band-gap change achievable over the previous superlattice, and thus the maximum achievable modulation in the nonlinear optical coefficients. Also, the superlattice waveguide core was terminated on both sides with barrier Al<sub>0.85</sub>Ga<sub>0.15</sub>As layers instead of GaAs to avoid the formation of reduced potential barriers with the adjacent buffer layers which consisted of 300-nm-thick Al<sub>0.56</sub>Ga<sub>0.44</sub>As. Cladding layers were 800-nm-thick Al<sub>0.60</sub>Ga<sub>0.40</sub>As. A second lower cladding layer of 1- $\mu\text{m}$ -thick Al<sub>0.85</sub>Ga<sub>0.15</sub>As was added to improve confinement of the optical mode to the core layer. All layers were grown on a semi-insulating GaAs substrate by molecular beam epitaxy.

Intermixed superlattice samples were prepared by using the ion-implantation method. As<sup>2+</sup> ions were implanted with an energy of 4 MeV at a dosage of  $0.5 \times 10^{13} \text{ cm}^{-2}$ . Rapid thermal annealing of the implanted samples was carried out for 60 s at a temperature of 775 °C. Fig. 1 shows low-temperature (77 K) photoluminescence (PL) measurements of as-grown and intermixed samples. The PL peak for the as-grown material

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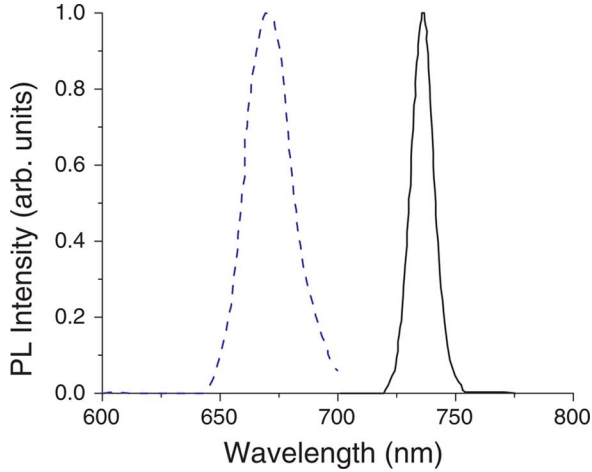


Fig. 1. PL spectra for as-grown (black solid) and intermixed (blue dashed) superlattice at 77 K.

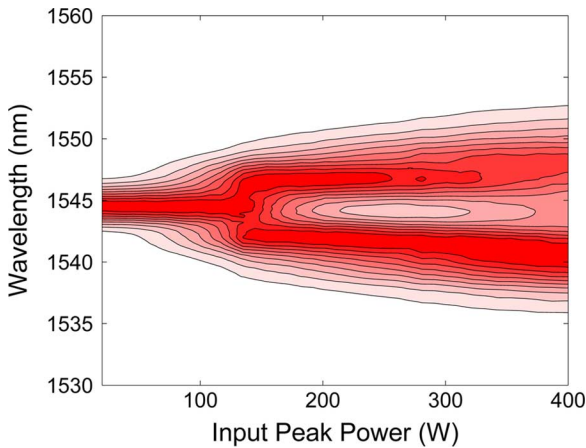


Fig. 2. Measured spectral broadening in as-grown waveguides at 1545 nm in the TM polarization.

places the half-band-gap energy within the 1550-nm telecommunications band. Intermixing shifted the PL peak by 68 nm, which is larger than the 40-nm shifts achieved with a conventional MQW [13]. Strip-loaded waveguides, each 3.0  $\mu\text{m}$  wide and 1.0  $\mu\text{m}$  deep were fabricated using reactive ion etching for both as-grown and intermixed samples. Linear losses were measured using the Fabry-Pérot method. For as-grown waveguides, loss coefficients averaged 0.55  $\text{cm}^{-1}$  for wavelengths around 1550 nm, while intermixed waveguides had average losses of 0.65  $\text{cm}^{-1}$ . Additional samples with ion doses of up to  $5 \times 10^{13} \text{ cm}^{-2}$  were also prepared and showed PL shifts of up to 85 nm, but with increasing values for the optical loss. The  $0.5 \times 10^{13} \text{ cm}^{-2}$  dose gave an appropriate balance between optical losses and band-gap shift.

Characterization of the waveguides was carried out using a singly-resonant optical parametric oscillator synchronously pumped by a mode-locked Ti:sapphire laser. Output pulses were 1.3–2.0 ps long at a repetition rate of 75.6 MHz. Light was end-fire coupled into waveguide samples using a 40 $\times$  objective lens with average powers of up to 250 mW. Spectral changes induced by self-phase modulation were recorded at the waveguide output with an optical spectrum analyzer as the input power was increased for both transverse-electric (TE)

and transverse-magnetic (TM) polarized inputs. Fig. 2 shows the evolution of the output spectrum with input peak power for the TM mode in the 5.7 mm-long as-grown sample at a center wavelength of 1545 nm. The point at which the spectrum splits into two peaks with a maximum dip in the middle is identified as the point where the nonlinear phase shift is  $1.5\pi$ . Ordinarily, the value of  $n_2$  is calculated by using this point as a reference. However, this simplistic method can underestimate the  $n_2$  by as much as 100%, especially since nonlinear absorption is not included in the calculation. It is potentially necessary to account for TPA, three-photon absorption (3PA), group-velocity dispersion (GVD), pulse shape, and chirp. The nonlinear Schrödinger equation (NLSE) describing the propagation of a pulse under such conditions can be written as

$$j \frac{\partial A}{\partial z} + j \frac{\alpha_0}{2} + j \frac{\alpha_2}{2} \frac{|A|^2}{A_{\text{eff}}^{(3)}} A + j \frac{\alpha_3}{2} \left[ \frac{|A|^2}{A_{\text{eff}}^{(5)}} \right]^2 A - \frac{\beta_2}{2} \frac{\partial^2 A}{\partial t^2} + \frac{2\pi n_2}{\lambda} \frac{|A|^2}{A_{\text{eff}}^{(3)}} A = 0 \quad (1)$$

where  $A(t, z)$  is the pulse envelope and represents the square root of the optical power, and  $\alpha_0$  is the linear loss coefficient. The TPA and 3PA coefficients,  $\alpha_2$  and  $\alpha_3$ , were determined by a combination of inverse transmission methods [4] and numerical fits of the transmission curves. GVD coefficients  $\beta_2$  were calculated from the dispersion of the effective index of the waveguides reported in [14].  $A_{\text{eff}}^{(3)}$  and  $A_{\text{eff}}^{(5)}$  are the third- and fifth-order effective mode areas which are defined in [4] and were calculated to be between 4.5 and 6.0  $\mu\text{m}^2$  over the wavelength span of interest. Pulses were modeled as chirped super-Gaussian in shape. The NLSE was solved numerically using the split-step Fourier method [15] to obtain simulated spectral evolution plots. The simulation was repeated for various values of the waveguide effective  $n_2$  until the calculated spectral evolution matched the measured data.

The  $n_2$  values obtained from matching the spectral broadening were that of the waveguide structure as a whole. To evaluate the behaviour of the superlattice layer before and after intermixing, it was necessary to deconvolve the value of  $n_2$  for the core layer alone. This was done by accounting for the overlap of the optical mode with the buffer and cladding layers [12]. The value of  $n_2$  in those layers was calculated from measured values of bulk  $\text{Al}_{0.18}\text{Ga}_{0.82}\text{As}$  [4] and the scaling laws for  $n_2$  [16]. The resulting core layer  $n_2$  values for as-grown and intermixed superlattice are shown in Fig. 3. Error bars reflect uncertainties in the linear loss,  $A_{\text{eff}}^{(3)}$ , and pulse chirp, and the variance in  $n_2$  which gives matched spectral patterns. The magnitude of the measured values is similar to bulk  $\text{Al}_{0.18}\text{Ga}_{0.82}\text{As}$  [4]. However,  $n_2$  is smaller than in the previous superlattice structure [12], which is attributed to a elimination of parasitic ASQWs in the new superlattice structure. A strong polarization anisotropy is observed in both superlattice structures with the TE polarization having  $n_2$  values nearly three times larger than the TM polarization in the present structure. This is due to lifting of the light/heavy-hole valance band degeneracy which places the half-band-gap resonance of the TM polarization at a shorter wavelength than the TE polarization [17]. Intermixed superlattice had  $n_2$  values suppressed by as much as 71% in the TE polarization and 33% in the TM polarization. The polarization dependence after intermixing was substantially reduced, which

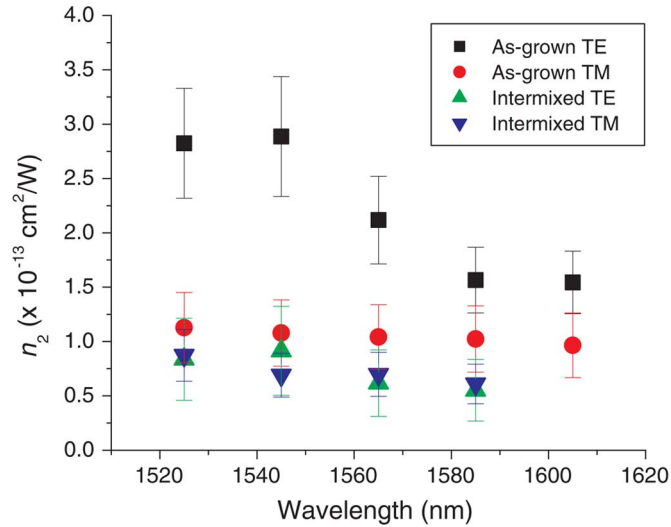


Fig. 3. Measured  $n_2$  values for as-grown and intermixed superlattice.

indicated that the superlattice reverted to a more bulk-like material.

In comparison to previous work on intermixing MQW waveguides [13], the observed suppression of  $n_2$  in the superlattice is up to 11% larger. Furthermore, the present intermixing technique and dosage is less traumatic to the underlying crystalline structure, i.e., it is not fully intermixed with commensurate lower optical losses, and provides a higher spatial resolution. The new superlattice improves over the previous superlattice structure with a reduction in parasitic TPA. This yields a better nonlinear figure-of-merit, defined as  $T = 2\alpha_2\lambda/n_2$  [12]. For 1545 and 1565 nm in the TE mode,  $T < 0.5$  which indicates that complete switching in an NLDC is possible. At 1525 nm, which is above the half-band-gap energy, TPA increased significantly and the value of  $T$  was above the required value of 1. Above 1565 nm, TPA is nonexistent and 3PA becomes the dominant nonlinear loss mechanism. However, suppression of  $n_2$  after intermixing is significantly reduced at these longer wavelengths. Thus, optimal wavelengths for switching are between 1545 and 1565 nm which are close enough to the half-band-gap resonance to enhance  $n_2$  while still having low TPA values.

In conclusion, suppression of the Kerr effect was measured in GaAs–AlGaAs superlattice-core waveguides after QWI by ion implantation. Ion doses of  $0.5 \times 10^{13} \text{ cm}^{-2}$  resulted in a 68-nm shift of the PL peak after annealing. Values for  $n_2$  were reduced in the intermixed superlattice by as much as 71% in the TE mode due to shifting of the half-band-gap resonance. An observed polarization anisotropy to  $n_2$  of 63% in the as-grown superlattice was substantially reduced in the intermixed material.

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